# The Structure and Stokes Shift of Hydrogenated Silicon Nanoclusters

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### Abstract

We evaluate the optical gap and Stokes shift of several candidate 1 nm silicon nanocrystal structures using density functional and quantum M onte C arb (QMC) methods. We nd that the combination of absorption gap calculations and Stokes shift calculations may be used to determ ine structures. We nd that although absorption gaps calculated within B 3LYP and QMC agree for spherical, completely hydrogenated silicon nanocrystals, they disagree in clusters with di erent surface bonding networks. The nature of the Stokes shift of the ultrabright lum inescence is exam ined by comparing possible relaxation mechanisms. We nd that the exciton which reproduces the experimental value of the Stokes shift is most likely a state formed by a collective structural relaxation distributed over the entire cluster.

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### I. IN TRODUCTION

The investigation of sem iconducting nanoclusters is one of the most promising directions in the search for new materials to construct optical and electronic devices, new laser materials, and biological markers<sup>1,2,3</sup>. The properties of nanosize clusters are typically very di erent from their parent bulk compounds; for example, surface passivated silicon nanoclusters show a number of interesting e ects such as ultrabright lum inescence<sup>4,5,6,7,8,9</sup> and nonlinear optical e ects<sup>0</sup>, whereas crystalline bulk silicon is optically uninteresting because of its sm all and indirect gap. P revious theoretical studies have employed various m ethods to m odel and understand the basic structural and electronic properties of nanosize clusters such as tight-binding<sup>11</sup>, empirical pseudopotentials<sup>12</sup>, density functional theory (D FT)<sup>13,14</sup>, GW Bethe Salpeter (GW BSE)<sup>15,16</sup>, and quantum M onte C arb (QMC)<sup>17</sup>. D espite the signi cant progress that has been m ade, especially in interpreting the properties of larger clusters (> 2 nm , > 500 atom s), m any open questions still exist as to how new physical e ects begin to dom inate the electronic structure of these clusters as the surface to volum e ratio increases. These e ects include the possibility of surface states, reconstructions, and in purities.

Recent opticalm easurements of silicon nanocrystals synthesized in macroscopic quantities using a process of rst etching and then sonically breaking up a silicon wafer<sup>18</sup> appear to have predominantly spherical shapes, show ultrabright luminescence, and are produced in remarkably uniform batches. The smallest silicon nanoclusters in the range of 1 to 1.2 nm<sup>18</sup> synthesized through this method exhibit signi cantly di erent properties compared with predictions from previous studies such as smaller absorption gaps and di erent red shifted emission peaks (i.e. the Stokes shift)<sup>11,12,19,20,21,22,23</sup>. Understanding the di erences in these two characteristics call for high quality electronic structure calculations which can precisely describe the e ects of electron correlation in ground and excited states, charge transfers, and di erent surface bonding networks.

In this article, we present a state-of-the-art com putational study of 1 nm hydrogenated Si nanocluster prototype systems in order to understand the interplay between their electronic and optical properties, their surface states and structures, and to interpret their absorption and emission processes. We employ a combination of high accuracy ab initio methods including DFT (using the local density approximation (LDA) and the Perdew

Burke Emzerhof (PBE)<sup>24</sup> and B3LYP avors of the generalized gradient approximation (GGA)) and QMC to elucidate the electronic and structural properties of the most relevant structural prototypes. We focus on system s with 50 to 70 total atom s which are consistent with the observed sizes that emit in the blue or at the UV edge ( 2.90 eV). We nd that surface dimerization is considered as the best possible mechanism for the occurrence of sm aller gaps and Stokes shifts than would otherwise be expected in this size range<sup>25</sup>. We use our derived models to study the structural and electronic e ects related to the observed Stokes shift, namely the energy di erence between absorbed and em itted photons and the character of the corresponding exciton state. The high accuracy of our QMC calculations enables us to deduce that the mechanism most likely to be responsible for the Stokes shift in these systems is due to a global relaxation of the cluster rather than the stretch mode of a single surface dim er<sup>23</sup>. Our results dem onstrate that the accurate calculation of a com bination of properties is critical for a full understanding of surface reconstructions, doping, and the Stokes shift of nanoclusters in this size range. Finally, we did that despite its agreem ent in determ ining optical gaps for spherical silicon nanocrystals, B 3LY P com pares less favorably with QMC results for system s with reconstructed surfaces or with oxygenated surfaces.

### II. CALCULATIONAL METHODS

To construct structural prototypes, we start from the bulk silicon lattice and choose a spherical region as this has the smallest surface area for a given number of atom s. The dangling bonds on the surface are saturated with hydrogen and the term inated Si atom s are classi ed into -SiH,  $-SiH_2$  and  $-SiH_3$  types. The structures with  $-SiH_3$  are discarded as they are energetically less favorable and therefore prone to reactions with the environment. Considering prototypes with -SiH and  $-SiH_2$  term inations in the 1-1.2 nm size regine leads to two likely ideal structures,  $Si_{29}H_{36}$  and  $Si_{55}H_{36}$  (Fig. 1). In some cases, DFT calculations using a planewave basis and norm -conserving pseudopotentials<sup>26</sup> are used to establish the equilibrium geometries and the electronic structure of these systems with a kinetic energy cuto of 35 Ry, a G ianozzi pseudopotential for hydroger<sup>27</sup>, and a H am ann pseudopotential for all other atom s<sup>28</sup>. In other cases, G aussian all-electron calculations using a 6-311G basis is used<sup>29</sup>. A swe have previously observed<sup>17</sup>, the relaxed structures are very sin ilar when

calculated using either LDA or gradient corrected (PBE) functionals and are fairly close to the original bulk derived structures with sm all adjustments of the bond lengths and angles, predom inantly of the surface atoms. For each cluster, the highest occupied molecular orbital (HOMO)/ lowest unoccupied molecular orbital (LUMO) gap is calculated using LDA, PBE, and the B3LYP functional.

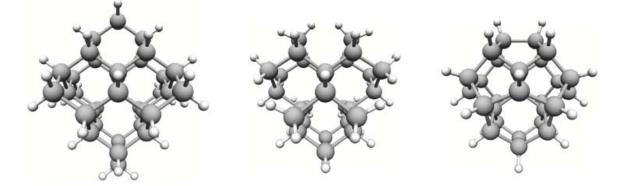


FIG.1: A tom ic structures of  $Si_{25}H_{36}$ ,  $Si_{29}H_{36}$ , and  $Si_{29}H_{24}$  nanocrystals. The larger spheres represent Si atom s while the smaller ones the hydrogens. Note the surface reconstruction of the top dimer from  $Si_{29}H_{36}$  to  $Si_{29}H_{24}$ .

A lthough DFT techniques produce accurate m in im um energy structures of silicon nanoclusters and also reliably predict the trends in the optical gap of a given structural type as a function of size<sup>17</sup>, a m ore accurate approach, for example, QMC which takes m any-body e ects into account is required to predict the di erence in optical gaps between di erent classes of structural prototypes, such as clusters with di erent surface passivants, clusters with reconstructed surfaces, or clusters with am orphous-like geom etries. In addition to the com puted DFT gaps, we therefore adopt a previously described QMC procedure<sup>30,31</sup> to perform QMC calculations using the CASINO code<sup>32</sup> for the optical gaps discussed in this paper.

III. PREDICTED STRUCTURE THROUGH COMPARISON W ITH ABSORP-TION GAP

The smallest experimentally measured clusters are determined to be 1 nm in diameter<sup>18</sup>. 1 nm clusters are too small to observe crystallinity using transmission electron microscopy (TEM), so the structure must be discerned from other experimental methods,

or deduced from physical properties such as the absorption gap and the Stokes shift. Indeed, even if TEM or other methods were capable of resolving the crystallinity of 1 nm clusters, it could not predict the surface chemistry. In a previous work, we can pared the absorption gap of 1 nm spherical silicon nanoclusters with two types of reconstructed surfaces<sup>25</sup>. Am ongst the various structures analyzed, only clusters with reconstructed dimers yielded results consistent with the experimentally measured gaps. However, in addition to all possible oxygenated clusters which were not considered, a recent molecular dynam – ics calculation predicted that am orphous-like 1 nm clusters can have similar gaps to those with reconstructed dimers<sup>33</sup>. Here, we have recalculated the gaps of these ideal and reconstructed clusters, now using linear scaling QMC <sup>30,32</sup> which has allowed us to obtain much sm aller statistical errors, and com pared them with the double cored clusters<sup>33</sup> as well as various oxygenated clusters. For com parison, we also com pute all relevant HOMO /LUMO gaps within DFT using various functionals, focusing on the B 3LYP functional in order to make a more com plete com parison of this functional with com putationally demanding many-body QMC results.

Table 1 shows that the optical absorption gaps as calculated within QMC of two com – pletely hydrogenated spherical crystalline nanoclusters about 1 nm in diam eter,  $Si_{29}H_{36}$  and  $Si_{35}H_{36}$  (5.3 and 4.9 eV) are larger than our experimentally measured value of  $3.5 \text{ eV}^{18}$ , while the crystalline cluster with reconstructed dimers are in agreement with experiment as previously show  $n^{25}$ . A comparison with oxygenated clusters indicates that those with bridged oxygen are signile cantly higher than our experimental gaps, while those with double bonded oxygen are signile cantly lower, in both cases dilering by over 1 eV. However, these gaps are consistent with the calculated gaps of double core am orphous-like clusters<sup>33</sup>, suggesting both structures should be analyzed further.

In order to better understand the possibility of (2 1) dim er reconstructions, we consider here the therm odynam ics of the reconstruction. W hile the kinetics of such a reconstruction are beyond the scope of this paper, to dem onstrate that a (2 1) reconstruction is possible, we compared the total energies of the \reaction"  $Si_{29}H_{36}$  !  $Si_{29}H_{34} + H_2$ . We found that within GGA m ethods, the balance is -0.3 eV (endotherm ic at T=0) and therefore such a dimerization m ay well occur for suitable dhem ical potentials of hydrogen. Since the preparation of the nanocrystals is perform ed in a m ixture of HF and  $H_2O_2$ , and indeed the presence of the peroxide is crucial for obtaining the spherical shapes and nearly uniform

	LDA	B 3LY P	QMC
Si <sub>29</sub> H <sub>36</sub>	3.6	52	53(1)
Si <sub>35</sub> H <sub>36</sub>	3.4	5.1	5.0(1)
Si <sub>29</sub> H <sub>24</sub>	2.6	4.0	3.5(1)
Si <sub>30</sub> H <sub>22</sub>	22	( )	3.1(1)
Si <sub>29</sub> H <sub>34</sub> O	3.1	4.8	4.7(1)
Si <sub>35</sub> H <sub>34</sub> O	22	3.9	2.6(1)
Si <sub>35</sub> H <sub>24</sub> O <sub>6</sub>	1.7	33	(1.7)

TABLE I: Calculated optical gaps (eV) of some prototype 1 nm clusters using three di erent methods. The statistical errors in the QMC values are in parenthesis.

sizes, one could also envisage the reaction  $Si_{29}H_{36} + H_2O_2$  !  $Si_{29}H_{34} + 2H_2O$ . Since the oxygen-oxygen distance its reasonably well with the neighboring hydrogens on the two Si atom s such a reaction suggests a short reaction path and the process is exotherm ic in GGA by 2.7 eV. A lthough the presence of  $H_2O_2$  could also induce additional oxidation reactions of the cluster, these reactions produce clusters with absorption gaps considerably smaller than those measured here when double bonded to the surface, and larger when in a bridged con guration<sup>31</sup>.

Recently, DFT calculations with the B3LYP functional have received some attention as a relatively computationally inexpensive alternative to such many-body methods as couple cluster, GW BSE, and QMC for determining accurate absorption gaps<sup>20,34,35</sup>. Table 1 shows calculated gaps of Si<sub>29</sub>H<sub>34</sub>O with oxygen bridged to the surface, and Si<sub>35</sub>H<sub>34</sub>O and Si<sub>35</sub>H<sub>24</sub>O<sub>6</sub> with oxygen double bonded to the surface using the B3LYP functional. In each case, the gaps of the clusters with double bonded oxygen are signic cantly lower than the observed gaps of our 1 nm clusters but in complete disagreement with recent QMC studies. B ased on the B3LYP gaps, one would conclude that our clusters are passivated by multiple double bonded oxygen atoms, specic cally Si<sub>35</sub>H<sub>24</sub>O<sub>6</sub> (3.3 eV B3LYP gap), while the QMC results indicate otherwise. Conversely, the double core structures have gaps 1 eV higher than the experimentally measured values, when calculated within B3LYP, which would tend to eliminate these clusters as candidates. Therefore, we conclude through comparison of the absorption gap with QMC values, and through simple therm odynamic considerations, that these clusters either have (2 1) reconstructed surfaces, although they still m ay be am orphous, and that like other DFT functionals, B 3LY P m ay only generate trends that are in agreem ent with QMC and not quantitative values.

# IV. DOPING AND CONTAM INATION OF RECONSTRUCTED SILICON CLUS-TERS

In the previous section, we calculated the e ects of oxygen and compared with our 1 nm prototype cluster with a reconstructed surface. In this section, we consider the e ect of other contam inants, dopants, and functionalizing groups bonded to the surface of these nanoclusters. We have calculated the absorption gap of reconstructed clusters with a variety of groups and once again compared the optical gaps predicted by QMC with the single-particle B 3LYP gaps. In our previous study of unreconstructed clusters, double-bonded groups were found to reduce the gap of 1 nm clusters by as much as 2.5 eV, while single-bonded groups reduced the gap a negligible am ount<sup>17</sup>. Therefore, the completely hydrogenated Si<sub>29</sub>H<sub>36</sub> cluster yields a 5.3 eV gap, higher than our observed 3.5 eV gap, while clusters with double-bonded passivants yield gapsm uch sm aller (2.0 to 2.7 eV). This supports the (2 1) reconstructed Si<sub>29</sub>H<sub>24</sub> cluster with a gap of 3.5 eV as a likely candidate structure for our experiment<sup>25</sup>. To complete the picture, we now consider the additional e ect of passivant groups on this reconstructed cluster, which has heretofore not been considered.

Table 2 shows that our calculated LDA and B3LYP single-particle gaps for a range of groups single-bonded to the surface of  $Si_{29}H_{24}$ . We consider common contaminants from our synthesis process (F and OH), groups typically used to dope semiconductors (NH<sub>2</sub> and PH<sub>2</sub>), and groups used to functionalize the surface (CH<sub>3</sub> and SH). For all these groups, the reduction of the single-particle gap compared to the prototype  $Si_{29}H_{24}$  cluster is minimal (< 0.1 eV) similar to the small e ect of single-bonded groups on unreconstructed clusters<sup>17</sup>. We nd that this trend exists for calculations based on the LDA, PBE, and B3LYP functionals. This lack of an e ect is perhaps not surprising given that the bonding network between the surface and these single bonded passivants is the sam e as with hydrogen. The interplay between the dimerization (the already distorted sp<sup>3</sup> network) and these various passivants is thus negligible demonstrating that the dom inant e ect on the gap of  $Si_{29}H_{24}$  is the surface reconstruction, not the presence of single-bonded passivants.

LDA/PBE	ВЭГІЬ			
2.7	3.9			
2.6	3.9			
2.5	3.7			
2.6	3.9			
2.5	3.8			
2.6	3.8			
2.7	3.9			
Bridge Doping				
2.7	4.0			
2.6	3.8			
2.7	3.9			
	2.7 2.6 2.5 2.6 2.5 2.6 2.7 2.7 2.6			

Appendage Doping LDA / PBE B3LYP

TABLE II: Calculated optical gaps (eV) of dopants on reconstructed clusters using various functionals within DFT either connected to one silicon atom (appendage doping) or between two atoms (bridge doping).

W hile the e ect of single-bonded passivants is small, we found that the SH and OH groups a ect the nanocrystal gap more than other single-bonded passivants yielding a 0.2 eV red shift, similar to the observed gap reduction in OH on an unreconstructed cluster<sup>17</sup>. In each case, the addition of the bent group tends to distort the binding geometry at the surface, be it  $Si_{35}H_{35}OH$ , or  $Si_{29}H_{23}SH$ . The addition of a longer hydrocarbon chain to the SH (C<sub>4</sub>H<sub>8</sub>SH), completely eliminates this red shift as now the longer hydrocarbon chain causes less distortion at the surface. Therefore, our results show that caution should be used when using single atoms to model the e ect of foreign substances on the surface of silicon nanoclusters; these single atom models tend to distort the surface to a greater extent and thus overestim ate the a ect on the gap compared with longer chains.

D opants m ay also form in a bridged con guration which m ay potentially lower the gap further when coupled with dimerization. Previous calculations have shown that in  $Si_{29}$ clusters, the formation of bridged oxygen is energetically favorable to double-bonded oxygen<sup>31</sup>. In Table 2, we compare the gaps of a number of additional dopants in an Si-X -Si con guration with X = S, NH, and  $CH_2$ . The Si-X-Sibridge replaces a reconstructed dimer on the surface. Again, we not the elect of these bridged dopants is negligible.

These m inim al shifts in the optical absorption gap m ean that single-bonded and bridged contam inants cannot be distinguished from fully hydrogenated clusters in optical absorption m easurem ents and thus m ay be present on our clusters. The calculation of other physical properties such as the Stokes shift are then required for additional characterization.

## V. STOKES SHIFT

### A. Mechanism

O ne of the most intriguing features of nanocrystals is the possibility of forming selftrapped excitons which are closely related to the Stokes shift. This possibility has been the subject of several recent studies using a variety of models<sup>21,22,23,36</sup>. In particular, A llan et al. have exam ined models involving both a relaxation mechanism involving the entire cluster<sup>21</sup> and more recently a model based on the assumption that, after absorption, the exciton leads to a stretching of a particular surface Si-Sidim erbond, to form a self-trapped exciton<sup>23</sup>. The motivation for reexam ining a range of dimension of the observation that many experiments on 1 nm clusters appear to lead to pronounced Stokes shifts. However, in our experiments we obtained values of  $0.4 - 0.5 \text{ eV}^{18}$  which are signing anally smaller than previously calculated 1-2 eV for this range of sizes<sup>23,37</sup>. By calculating the Stokes shift in ideal 1 nm clusters, in those with reconstructed surfaces, in those with bridged oxygen, and in double-core am orphous-like clusters, we hope to demonstrate the use of the Stokes shift as a useful characterization method.

Before comparisons of the excitations in diement structural prototypes can be made, we rst need to determ ine the appropriate relaxation mechanisms. To resolve this issue we have performed ab initio calculations of the relaxation of the candidate structures discussed above in both the ground and excited (excitonic) electronic states. In addition, we have used QMC calculations to provide highly accurate values for the electronic gaps of the ground and excited state structures to accurately determine the magnitude of the Stokes shift associated with each model. Since it is computationally easier to relax the electronic structure in the optically forbidden triplet excited state, we used the triplet state to carry out

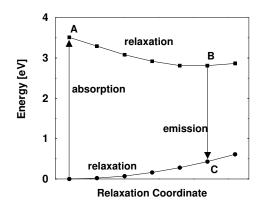


FIG.2: Illustration of the Stokes shift in  $Si_{35}H_{34}$  within the collective relaxation mechanism using energies from local density approximation calculations.

m ost of geom etry scanning and relaxation calculations. For a few points on energy surfaces we have veri ed that the singlet and triplet energies were within 0.03 eV. Therefore, the m easured Stokes shift is about an order of m agnitude larger than the singlet-triplet splitting, in direct contradiction to the m odel proposed by Takagahara<sup>22</sup> for the Stokes shift in silicon nanoclusters.

To compare di erent Stokes shift mechanisms, we choose to study the  $S_{29}H_{34}$  structure. This cluster has the same structure as the  $S_{29}H_{36}$  prototype, except that one of the  $-S_{1}H_{2}$  surface pairs has been reconstructed to form a dimer. By studying the Stokes shift in this cluster we are able to exam ine the competition between a dimer localized Stokes shift and a global relaxation of the cluster. In addition, we are able to compare with previous studies<sup>23,38,39</sup> of this system. In Fig.2 we plot the LDA total energy of a  $S_{29}H_{34}$  nanocrystal in both the ground state (lower curve: circles) and excited state using the ground state structure total energy as a reference. O noe the photon is absorbed (point A) the system is in the excited state and the slower (piceseconds) structural relaxation occurs.

The decrease in the energy from the point A to B is due to the collective relaxation of all atom ic positions of the entire cluster without any constraint except that the system is in the excited electronic state. In the two symmetric clusters, either the unreconstructed  $Si_{29}H_{36}$ , or the  $Si_{29}H_{24}$ , the excitation is formed by promoting an electron from the p-like HOMO to the s-like LUMO, leading to a small distortion of the cluster from a spherical to slightly elliptical geometry. The position C corresponds to the state after photon emission and before the subsequent relaxation to the ground state. The key features which emerge

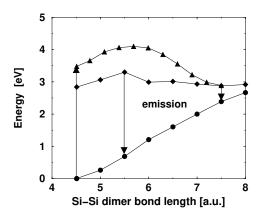


FIG. 3: Density functional Stokes shift calculations of  $\rm Si_{35}H_{34}$  within the local bond-breaking relaxation mechanism .

from our calculations are: a) barrierless relaxation to a lower energy geom etry and b) sm all geom etry adjustments of 0.01 A of essentially all atoms in the cluster.

In Fig. 3 we analyzed the model of a self-trapped exciton based on a stretching and breaking of the single dimer bond, as proposed in Ref.<sup>23</sup>. The geometries used to generate the upper triplet curve (triangles) were obtained by linearly interpolating the atom ic positions between the ground state geometry ( $d_{SiSi} = 2.4 \text{ A}$ ) and the local minimum energy structure obtained when  $d_{SiSi}$  was constrained to 4.0 A. This upper curve closely reproduces the calculation originally presented in Fig. 2 of Ref.<sup>23</sup> for this system, where the interm ediate structures were also derived from linear interpolation. The points on the lower curve (diam onds) were obtained by constraining the dimer bond length, d, to a series of diment values, while allow ing all other atom s to relax while keeping the system in the excited state.

Examining Fig.3, we observe that if the system goes along the structural path leading to the broken dimer bond, it is that to overcome a barrier of 0.5 eV due to the elastic energy of the cluster before the energy decreases as the bond breaks ( $d_{\text{SiSi}} > 2.9 \text{ A}$ ). It is interesting that them inimum energy of the excited state resulting from the global relaxation in Fig.3 is almost identical (2.8 eV) to the minimum obtained by breaking the dimer, 2.9 eV. However, the important di erence is in the large energy increase on the ground state path which in turn leads to a very large Stokes shift and sm all energy of the emitted photon. The curve represented by interpolating the atom is coordinates between the ground state structure and the structure of a broken dimer ( $d_{\text{SiSi}}$  4.0 A) as suggested in Ref.<sup>23</sup> yields a markedly di erent energy surface to the more realistic case in which all the atom s, except

the dimer, are relaxed for each dimer length.

We have also exam ined the Stokes shift relaxation mechanism proposed in Ref.<sup>39</sup> where a hydrogen atom attached to one of two neighboring SiH surface groups moves into a bridged position between the silicon atom s and the SiSi bond stretches. In contrast to the sem iempirical calculations used to predict this structure<sup>39</sup>, our density functional calculations do not nd this structure to be a meta-stable state. We nd a spontaneous relaxation from this proposed bridge structure to a structure in which the bridged hydrogen is completely transferred to the neighboring Si, producing an SiH<sub>2</sub> group and a Siw ith a dangling bond. Interestingly, this structure is energetically competitive (3.1 eV above groundstate) with the relaxed excited state structures shown in Figs. 2 and 3. However, as with the dimer breaking mechanism illustrated in Fig. 3, there is a signi cant energy barrier between the groundstate structure and this one.

Based on these results, three di erent m echanism s from which a Stokes shift could result are possible. A ffer absorbing a photon the cluster could then: i) relax via the collective structural m echanism (Fig. 2) to point (B) where the electron and hole then vertically recombine to point (C); or, ii) absorb enough energy from thermal uctuations or higher vibronic states<sup>40</sup> to overcom e the barrier and either break the dim  $er^{23}$  or transfer a hydrogen<sup>39</sup> with subsequent em ission and relaxation to the ground state (Fig. 3, triangles); or, iii) absorb enough energy from thermal excitations to partially stretch the dim er and to recombine from the top of the barrier. The LDA values of the Stokes shift for these three m echanism s are 1.1, 3.0 and 0.9 eV, respectively. The signi cantly larger Stokes shift for m echanism ii) arises m ostly from the large increase in the ground state energy associated with the stretching of the dim er bond. At the minimum of the excited state, the dim er is e ectively broken and the ground state energy has increased by 2.5 eV, the energy required to create two dangling bonds.

G iven the very large Stokes shift associated with the creation of a surface dimeror transfer of hydrogen, coupled with the signicant barrier that inst has to be overcome before it is energetically favorable to stretch the dimer, we believe that the mechanism most likely to be responsible for the Stokes shift is the global relaxation mechanism of Fig. 3. We have therefore calculated within both DFT (LDA and GGA) and QMC the values of the total energies at points A to C for the three candidate structures.

The QMC values for the Stokes shifts (Table 3), de ned as  $(E_A = E_{ground})$   $(E_B = E_C)$ , for  $Si_{29}H_{36}$ ,  $Si_{29}H_{24}$  and  $Si_{35}H_{36}$  are 1.1, 0.42 and 0.8 eV, respectively, and agree well with those predicted by LDA and PBE which are about 0.1 eV higher in each case. W hile the decrease in value between the  $Si_{29}H_{36}$  and the  $Si_{35}H_{36}$  cluster demonstrates clearly the size dependence of ideal spherical silicon nanoclusters, the QMC value of  $Si_{29}H_{24}$  is in closest agreement with the measured value of  $0.45 \text{ eV}^9$ . Therefore, when combined with our estimation for the gap,  $Si_{29}H_{24}$  remains a realistic prototype for both the structure and excited states processes observed in our experiments.

Stokes Shift

	LDA	QMC
Si29H 36	1.1	1.0
Si <sub>35</sub> H <sub>36</sub>	0.8	0.7
Si <sub>29</sub> H <sub>24</sub>	0.5	0.45
Si <sub>30</sub> H <sub>22</sub>	3.0	

TABLE III: Calculated Stokes shifts (eV) of some prototype 1 nm clusters calculated within LDA and QMC. The large shift in  $Si_{30}H_{22}$  renders the QMC unnecessary.

We also consider here the non-crystalline 1 nm clusters which have been predicted to form during chem ical vapor deposition at high temperatures by quantum molecular dynamics (Q M D) simulations<sup>33</sup>. Although not applicable to the soni cation process demonstrated here, these non-crystalline clusters were shown to have a gap comparable to those with ideal reconstructed clusters. We calculate the Stokes shift of these clusters to ascertain whether they have the 0.4 to 0.5 eV Stokes shifts observed in our clusters and predicted for reconstructed clusters. Surprisingly, we not very large Stokes shifts, on the order of the gap size! These non-crystalline 1 nm clusters behave more like sm all molecules<sup>41</sup> than quantum dots. Thus, the Stokes shift has proved a very powerful characterization technique elim inating the \double core" non-crystalline clusters as being those observed here.

#### VI. CONCLUSION

In conclusion, we have carried out a thorough study of hydrogen term inated silicon nanoclusters in the 1-1.2 nm range. We investigated several prototype structures and compared their optical absorption gaps and Stokes shifts with recent measurements and found that although a few other structures may yield a similar gap, most notably an amorphous-like double core cluster, only Si<sub>29</sub>H<sub>24</sub> yields both the correct gap and Stokes shift. Thus, we determ ine that both properties must be considered when evaluating candidate structures to interpret optical measurements. We determ ined that B 3LY P generates inconsistent results for clusters with localized orbitals compared with QMC level calculations. The atom istic

rst-principles DFT approaches coupled with QMC allowed us to study the optically induced excitons and to conclude that the most likely mechanism causing the Stokes shift is the barrierless relaxation of the whole structure with the red shift of 0.4 eV in agreement with experiment. Comparison with further experimental data indicates that the  $\text{Si}_{29}\text{H}_{24}$ structural prototype is the most promising candidate of the possibilities we tested. We have also investigated the elect of doping with a number of atom s and molecular groups. Like ideal unreconstructed structures, sp<sup>3</sup> bonded passivants have a minimale lect on absorption gaps, as do single bridged passivants. Therefore, other atom s or ligands may be used to functionalize these clusters with no discernible change to the gap.

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